Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S45	2	("5141596").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:07
S46	35	("5141596").URPN.	USPAT	OR	OFF	2005/10/11 14:07
S47	63	(ohkuma and norio).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:18
S48	696	(etch\$3 and silicon and (doped or doping) and (through-hole or opening or hole or passage\$3 or slot) and (arsenic or boron or phosphorus or antimony)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:26
S49	257	(etch\$3 and silicon and (doped or doping) and (through-hole or hole or slot) and (arsenic or boron or phosphorus or antimony)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11:14:30
S50	4320	(etch\$3 adj stop).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:36
S51	1080	S50 and (trench\$2):clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:31
S52 .	808	S50 and (hole\$1 or thru-hole\$1). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:32
S53	827	S50 and (hole\$1 or through-hole\$1 or thru-hole\$1 or slot).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	.2005/10/11 14:32
S54	517	S50 and (hole\$1 or thru-hole\$1 or slot).ab.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:33
S55	4926	(etch\$3 adj stop)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:36

S56	847	(etch\$3 adj stop) and trench\$2	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:37
S57	64	(etch\$3 adj stop) and ((ink adj jet) or inkjet)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:45
S58	1001	(etch\$3 adj stop) and ((ink adj jet) or inkjet)	US-PGPUB; USPAT	OR	OFF	2005/10/11 14:37
S59	56	(etch\$3 adj stop).clm. and ((ink adj jet) or inkjet).clm.	US-PGPUB; USPAT	OR	OFF	2005/10/11 14:38
S60	64	S57 or S59	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:38
S61	153	(high adj impurity adj concentration adj region).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF.	2005/10/11 14:48
S62	1	(high adj impurity adj concentration adj region).clm. and through-hole.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:49
S63	5	(high adj impurity adj concentration adj region).clm. and (through adj hole).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/11 14:50
S64	3	((ink adj jet) and (through adj hole) and (etch\$3 adj stop\$3)). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM TDB	OR	OFF	2005/10/11 14:51